

Form PTO-1449

U.S. DEPARTMENT OF COMMERCE  
PATENT AND TRADEMARK OFFICEATTY. DOCKET NO.  
MI22-1694SERIAL NO.  
09/885,393LIST OF ART CITED BY APPLICANT  
(Use several sheets if necessary)APPLICANT  
Richard Holscher et al.FILING DATE  
June 19, 2001GROUP  
1756

## U.S. PATENT DOCUMENTS

*Examiner Initial		Document Number	Date	Name	Class	Subclass	Filing Date If Appropriate
KMD	AA	5,413,963	05/09/95	Yen et al.	437	195	
	AB	6,143,670	11/07/00	Cheng et al.	438	780	
	AC	6,403,464 B1	06/11/02	Chang	438	623	
	AD	2001/0038919 A1	11/08/01	Berry, III et al.	428	446	
	AE	2002/0033486 A1	03/21/02	Kim et al.	257	118	
KMD	AF	2002/0081834 A1	06/27/02	Daniels et al.	438	624	
	AG						
	AH						
	AI						
	AJ						
	AK						

## FOREIGN PATENT DOCUMENTS

		Document Number	Date	Country	Class	Subclass	Translation	
							Yes	No
KMD	AL	EP 1 172 845 A2	01/16/02	EPO (Bayliss et al.)	—	—		
	AM	JP408213386A	08/20/96	Japan	—	—	x	(abstract only)
	AN	JP02000068261A	03/03/00	Japan	—	—	x	(abstract only)
	AO	TW 368687 A	09/01/99	TW	—	—	x	(abstract only)
	AP	TW 429473 A	04/11/01	TW	—	—	x	(abstract only)
KMD	AQ	TW 420844 A	02/01/01	TW	—	—	x	(abstract only)

## OTHER REFERENCES (including Author, Title, Date, Pertinent Pages, Etc.)

	AR	
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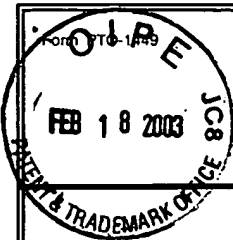
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M122-1694SERIAL NO.  
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## U.S. PATENT DOCUMENTS

*Examiner Initial		Document Number	Date	Name	Class	Subclass	Filing Date If Appropriate
KMD	AA	4,940,509	7/90	Tso, et al.	156	653	
	AB	5,429,987	4/95	Allen	437	187	
	AC	4,910,160	3/90	Jennings +	437	31	
	AD	6,200,835B1	3/01	Manning	438	158	
	AE	5,244,537	9/93	Ohnstein	156	643	
	AF	6,204,168B1	3/01	Naik et al.	438	638	
✓	AG	4,562,091	12/85	Sachdev +	427	41	
KMD	AH	4,764,247	8/88	Leveriza +	156	643	
	AI						
	AJ						
	AK						
	AL						

## FOREIGN PATENT DOCUMENTS

		Document Number	Date	Country	Class	Subclass	Translation	
							Yes	No
	AM							
	AN							
	AO							
	AP							
	AQ							

## OTHER REFERENCES (including Author, Title, Date, Pertinent Pages, Etc.)

	AR		Wolf, S., "Silicon Process for the VLSI Era, V.1 - Process Technology, Prologue, p. xxiii. Fig. 3
	AS		
	AT		

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